



APPLICATION DATA SHEET

APPLICATION INFORMATION

Application Type:: Regular
Subject Matter:: Utility
Title:: SUBSTRATE FOR PHOTOMASK, PHOTOMASK
BLANK AND PHOTOMASK
Attorney Docket Number:: Q80708
Request for Early Publication?:: No
Request for Non-Publication?:: No
Small Entity?:: No

APPLICANT INFORMATION

Applicant Authority Type:: Inventor
Primary Citizenship Country:: JAPAN
Status:: Full Capacity
Given Name:: Ryu
Family Name:: OHTAGURO
City of Residence:: Kumamoto
Country of Residence:: JAPAN
Street of mailing address:: 338-2, Kamimachi, Ozu-machi,
Kikuchi-gun,
City of mailing address:: Kumamoto
Country of mailing address:: JAPAN

Applicant Authority Type:: Inventor
Status:: Full Capacity
Given Name:: Koichi
Family Name:: HASHIGUCHI
City of Residence:: Kumamoto

Country of Residence:: JAPAN
Street of mailing address:: 4-4-142, Omine, Kumamoto-shi,
City of mailing address:: Kumamoto
Country of mailing address:: JAPAN

CORRESPONDENCE INFORMATION

Correspondence Customer Number:: 23373
Phone number:: (202) 293-7060
Fax Number: (202) 293-7860
E-Mail address:: sughrue@sughrue.com

REPRESENTATIVE INFORMATION

Representative Customer Number::	23373
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FOREIGN PRIORITY INFORMATION

Country::	Application number::	Filing Date::	Priority Claimed::
JAPAN	2003-084992	03/26/03	Yes
JAPAN	2004-073763	03/16/04	Yes

ASSIGNEE INFORMATION

Assignee name:: HOYA CORPORATION
Street of mailing address:: 7-5, Naka-Ochiai 2-chome,
Shinjuku-ku,
City of mailing address:: Tokyo,
Country of mailing address:: JAPAN